(1) Publication number:

0 155 749

A3

(12)

EUROPEAN PATENT APPLICATION

(21) Application number: 85300371.3

(22) Date of filing: 21.01.85

(5) Int. Cl.³: **C 25 D 3/54** C **25** D **3/02**, C **25** D **5/00** C **25** D **9/08**

(30) Priority: 23.01.84 US 572822

(43) Date of publication of application: 25.09.85 Bulletin 85/39

(88) Date of deferred publication of search report: 26.08.87

(84) Designated Contracting States: AT BE CH DE FR GB IT LI LU NL SE (71) Applicant: Rose, Robert M. 18 Morgan Street Wenham Massachusetts(US)

(71) Applicant: Sadoway, Donald R. 53 Vernon Road **Belmont Massachusetts(US)**

(72) Inventor: Rose, Robert M. 18 Morgan Street Wenham Massachusetts(US)

(72) Inventor: Sadoway, Donald R. 53 Vernon Road Belmont Massachusetts(US)

(74) Representative: Allsop, John Rowland Rowland Allsop & Co. Black Boy Yard 15 High Street West Wycombe High Wycombe, Bucks. HP143AE(GB)

54 Cryoelectrodeposition.

(57) A process for electrodeposition of a material on a substrate that includes the steps of establishing a liquid halogenous electrolyte containing the material to be plated on the substrate and a solute, said electrolyte having an appropriate electrical conductance in a cryogenic environment; and establishing an electric field within the electrolyte to effect migration of ions of said material to the substrate where they deposit.



EUROPEAN SEARCH REPORT

85 30 0371 EP

ategory	Citation of document with indication, where appropriate, of relevant passages		Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. CI.4)	
A,D	US-A-3 990 953 ((AUSTIN)		C 25 D C 25 D C 25 D	3/02 5/00
A	GB-A-1 367 872 (ATOMIC ENERGY CON			C 25 D	9/08
А	JOURNAL OF ELECTRELECTROCHEMICAL STATES 114, no. 7, July 655-658; R. KELLI "Low-temperature study using a mix N204"	SCIENCE, vol. 1967, pages ER et al.: battery system			
		us es			
				TECHNICAL FIELDS SEARCHED (Int. CI.4)	
				C 25 D C 25 D C 25 D C 25 D C 25 D H 01 L	3/02 3/54 3/66 5/00 7/12 39/24
	The present search report has be	Date of completion of the sear		Examiner of FFIIWEN	
	THE HAGUE	04-06-1987	VAN	LEEUWEN	K.H.

X: particularly relevant if taken alone
Y: particularly relevant if combined with another document of the same category
A: technological background
O: non-written disclosure
P: intermediate document

after the filing date

D: document cited in the application
L: document cited for other reasons

& : member of the same patent family, corresponding document